MOLECULAR DYNAMICS SIMULATION OF DAMAGE
CASCADE FORMATION IN ION BOMBARDED SOLIDS

A Thesis

by

DI CHEN

Submitted to the Office of Graduate Studies of
Texas A&M University
in partial fulfillment of the requirements for the degree of

MASTER OF SCIENCE

August 2011

Major Subject: Nuclear Engineering
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Approved by:

Co-Chairs of Committee, Lin Shao
Tahir Cagin
Committee Member, Xinghang Zhang
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August 2011

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ABSTRACT

Molecular Dynamics Simulation of Damage Cascade Formation in Ion Bombarded Solids. (August 2011)

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Co-Chairs of Advisory Committee: Dr. Lin Shao
Dr. Tahir Cagin

Presented in this thesis are the results from an integrated experimental and modeling study on damage cascade formation in ion bombarded solids. The molecular dynamics (MD) simulations were performed by using LAMMPS (Large-scale Atomic/Molecular Massively Parallel Simulator). In one subtask, we studied damage cascade interactions caused by two 2 keV Si atoms simultaneously bombarding a crystalline Si substrate. We found that the enhanced displacement creation appears primarily in the thermal spike stage with all atoms at energies less than the displacement threshold. The study lead to the conclusion that the cascade interactions increased local melting by increasing energy deposition density, thus promoting defect creation. In another subtask, we studied radiation damage in Si$_{0.8}$Ge$_{2}$ layer caused by Ag$_{n}$ clusters with number of atoms in a cluster, n, taking values from 1 to 4. It showed that strained SiGe, a material known to have poor radiation tolerance, still follows the overlap model, rather than the direct amorphization model. In the third subtask, MD simulation has shown that crowdion defects formed in bcc Fe are propagating along <111> directions. Crowdion defect starts to form when damage cascade reaches the maximum volume and contributes a second
peak in defect buildups with increasing times. Upon defect recombination, crowdion defects shrink and form $<111>$ oriented dumbbell defects at the crowdion end. In subsequent structural relaxation, $<111>$ dumbbell defects rotate and finally align themselves with $<110>$ directions. The surviving dumbbell defects represent a significant contribution to the final defect distribution after thermal spike formation.

The overall research reveals atomic scale details of damage buildups at early stages of defect developments. Although the target systems cover both semiconductor materials and metal, these results show that MD simulation is a powerful tool to show the details at a spatial and time scale beyond experiments. These details are very important to develop understanding the precursor formation in defect clustering in such a case.
DEDICATION

To my family
ACKNOWLEDGEMENTS

I would like to thank Dr. Lin Shao without whom this thesis would not have been finished. His supervision, advice, guidance, as well as encouragement and support were invaluable for me.

I would like to thank my co-chairs of committee, Dr. Tahir Cagin and committee member Dr. Xinghang Zhang for their help and support. Especially, Dr. Cagin, who gave me great help on my Molecular Dynamics simulation study. Without this study, I could not have finalized these projects. The members in Dr. Cagin’s group also offered me valuable information without any reservation.
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<table>
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<tr>
<th>Abbreviation</th>
<th>Full Form</th>
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<tr>
<td>Bcc</td>
<td>Body-Centered Cubic</td>
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<tr>
<td>EAM</td>
<td>Embedded-Atom Method</td>
</tr>
<tr>
<td>Fcc</td>
<td>Face-Centered Cubic</td>
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<tr>
<td>Fe</td>
<td>Ferrum</td>
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<td>Ge</td>
<td>Gallium</td>
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<tr>
<td>He</td>
<td>Helium</td>
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<tr>
<td>Kev</td>
<td>Kilo Electron Volt</td>
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<tr>
<td>LAMMPS</td>
<td>Large-scale Atomic/Molecular Massively Parallel Simulator</td>
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<tr>
<td>MD</td>
<td>Molecular Dynamics</td>
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<tr>
<td>Mev</td>
<td>Mega Electron Volt</td>
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<tr>
<td>Nm</td>
<td>Nanometer</td>
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<tr>
<td>PKA</td>
<td>Primary Knock-on Atom</td>
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<tr>
<td>Ps</td>
<td>Picoseconds</td>
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<tr>
<td>RBS</td>
<td>Rutherford Backscattering Spectrometry</td>
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<tr>
<td>Si</td>
<td>Silicon</td>
</tr>
<tr>
<td>SiGe</td>
<td>Silicon Gallium</td>
</tr>
<tr>
<td>SRIM</td>
<td>Stopping and Range of Ion in Matter</td>
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TDE  Threshold Displacement Energy (TDE)
V    Volt
ZBL  Ziegler, Littmark and Biersack
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CHAPTER I

INTRODUCTION

Radiation damage resulting from ion solid interactions has been a subject of intensive research efforts during the past decades [1]. Understanding radiation damage creation in solids is important for a wide range of application including ion implantation for device doping and development of radiation tolerant materials used under harsh environments involving particle bombardments [2]. While studies on semiconductors and insulators are primarily driven by the need for ion beam modification [3], studies on radiation damage in metals has been driven greatly by the needs for materials applications in harsh environments, i.e. fission and fusion reactors [1,4].

In a civilian thermal neutron reactor which includes the types of boiling water reactor and pressure water reactor, uranium oxide is used as nuclear fuels, which are surrounded by fuel cladding materials made of Zircaloy. Under normal operation conditions, the fuel center can reach a temperature as high as 800°C. There are huge amount of radiation damage occurring inside the fuel due to interaction of fission fragments, alpha, beta, gamma rays, and neutrons. The fission fragments have a typical kinetic energy of about 170 MeV (total), while the neutrons have a typical kinetic energy of 5 MeV. Both of them can lead to high energy recoil of fuel target elements.

This thesis follows the style of Nuclear Instrument & Methods in Physics Research B.
The creation of high energetic particles will lead to two primary ion solid interactions: electronic excitation of electrons and displacement of target nuclei from their original lattice sites. Due to large free flying path of neutrons, they will escape from the nuclear fuel and penetrate through the cladding materials and directly interact with coolant and other in-core structural components. For a typical reactor lifetime of 30 years, averagely a given target atoms in the fuel assembly will experience over 50 dpa, while the dpa stands for displacement per atoms. Such a high damage level significantly alters the microstructures of the in-core components. As a consequence, these materials have serious degradations including swelling, corrosion, embrittlement, cracking, blistering, flaking, etc. These radiations induced phenomena greatly limited the reactor lifetime and can cause reactor accidents. Fig.1 shows the typical radiation damage in nuclear reactor.

In advanced fission reactors, the overall operation temperatures are even higher. For example, in very high temperature gas cooled reactor, the temperature is above 1000°C for a better energy-electricity conversion. Furthermore, due to the needs in operation safety and non-proliferation risk control, these advanced designs also require a longer life times. Such prolonged service time and higher working temperature accelerate irradiation induced degradation. And generally, the advanced designs have less tolerance. For example, any swelling larger than 1% can cause safety issues.

In a fusion reactor, the irradiation environments are different from fission reactors. Not only the temperature is high, the first wall materials facing plasma also suffer severe neutron damage and simultaneous bombardments by low energy gas atoms such as
helium and deuterium. These gas atoms can stabilize the void formation and accelerate surface erosion.

Radiation damage affects each step of fuel cycles. For example, cracking during dry storage and permanent disposal is one serious issue. The container safety for spent fuel storage is still an issue unsolved. Any cracking can cause the leakage of radioactive materials and contamination of underground water systems.

Driven by the need to make reactor safer, as well as the needs for the next generation reactors, materials with enhanced radiation tolerance are needed. Towards this goal, we need to develop in depth understanding on the failure mechanism. Not limited to measure the macroscopic properties, studies need to reach microscopic details, and even atomic levels, to develop understanding necessary for materials engineering. This requires an integration of modeling and experimental studies. Particularly, due to limitation from current characterization tools, the knowledge on defect developments at a time scale and spatial scale beyond experiments are largely missing. Driven by this purpose, this thesis works is aimed to develop fundamental understanding by using atomic scale modeling.
For this purpose, the MD program LAMMPS (Large-scale Atomic/Molecular Massively Parallel Simulator) will be used to study non-linear damage caused by cluster ions under different conditions. LAMMPS is a classical molecular dynamics simulation code designed to run efficiently on parallel computers. It was developed at Sandia National Laboratories. It is an open-source code, distributed freely under the terms of the GNU Public License (GPL). The accuracy of MD simulation is directly determined by the interatomic potential used. In our study, we will use ZBL (Ziegler, Littmark and Biersack) model for short range interaction. The ZBL potential was developed by Ziegler, Littmark and Biersack two decades ago. It was extracted by best averaging of hundreds of interatomic potential and has been widely used in the field for ion solid
interaction. The smooth transition from long range potential to ZBL potential guarantees the accuracy in ion-solid interaction over a wide range of interaction distance. The final damage distribution, after typically a few picosecond, can be quantitatively extracted by counting the number of atoms having an energy a few eVs larger than bond energy.
2.1 Molecular Dynamics Background

Molecular dynamics (MD) is a computational method to predict the movement of one atom under a force contributed by other atoms of a typical size of millions. Such a movement goes back to contribute to the status of other atoms. Therefore, behaviors of individual atoms, as well as the global responses of a bulk sample, can be well predicted. The foundation of the MD simulation is the Newton’s second law. In order to integrate Newton’s equation, we can make such assumption that the position and the velocity of each atom can be calculated by Taylor’s expansion (2.1).

\[
\begin{align*}
    r(t + \delta t) &= r(t) + v(t)\delta t + \frac{1}{2}a(t)\delta t^2 + \\
    v(t + \delta t) &= v(t) + a(t)\delta t + \frac{1}{2}b(t)\delta t^2 + \\
    a(t + \delta t) &= a(t) + b(t)\delta t + \\
\end{align*}
\]

(2.1)

Where \( r \) is the position, \( v \) is the velocity, \( a \) is the acceleration. we can rewrite the displacements at small time steps as

\[
\begin{align*}
    r(t + \delta t) &= r(t) + v(t)\delta t + \frac{1}{2}a(t)\delta t^2 \\
    r(t - \delta t) &= r(t) - v(t)\delta t + \frac{1}{2}a(t)\delta t^2 \\
\end{align*}
\]

(2.2)

Summing these two equations, one obtains
This formula uses positions at time $t$ and $t - \delta t$ to calculate new positions at time $t + \delta t$.

One advantage by such calculation is that it largely reduces the errors introduced when a relatively larger time step is used. In most MD simulation, this formula is used as basic integration algorithms.

\[ r(t + \delta t) = 2r(t) - r(t - \delta t) + a(t) \delta t^2 \]  \hspace{1cm} (2.3)

### 2.2 The Simulation Proceeds

Fig.2 schematically shows MD simulation procedure. At beginning, positions and velocities of all atoms are defined, then forces are calculated based on the potential gradients. Then, displacement equations are solved for all atoms in the system over time step $\Delta t$ and physical quantities of interest are extracted, such as temperature, energy, pressure etc. If the total computational time satisfies $t < t_{\text{max}}$, the program will go back to the stage of calculating forces, so on repeating the steps within the loop, until finally $t = t_{\text{max}}$. 
2.3 Potentials in MD Simulations

The critical part of MD simulation is the force calculation, which depends on potentials. The accuracy of a MD simulation is determined by how accurate the interatomic potentials are. These potentials must come from more complicated quantum mechanics treatments. In many cases, even the most advanced calculations cannot serve the purposes well and a combination with experimental data is necessary to reflect the intrinsic properties of the materials. The primary approaches to get interatomic potentials include ab initio method, empirical method, and semi-empirical method.
Ab-initio methods totally rely on the quantum mechanics. The potentials are created by the quantum mechanical calculation based on solving a multi-body Schrödinger equations. The advantage of the method is that almost everything starts from the first principles. However, certain errors exist due to necessary assumptions and approximated used to simplify the process. Also certain details are not completely clear such as electron-electron interactions in heavy atoms.

Semi empirical potentials are also based on quantum mechanics calculation, but certain items are neglected in the calculation, For example, in Hartree-Fock calculations the overlapping of specific atomic orbitals are neglected, and the corresponding contribution is replaced by experimental results, in such a way the computations are less costly. For empirical potentials, the overlap of specific atomic orbitals are totally neglected and many free parameters are introduced to predict experimental observations.

2.4 Pair Potentials and Many-body Potentials

Pair potentials are used to describe the interactions between two isolated atoms, so it is also called pair potential. There are many ways to describe pair potentials, for example, one most popular one is Lennard-Jones potential [6], which is excellent for rare gas. Equation 2.5 is the mathematic form of Lennard-Jones potential. But it is oversimplified for describing other non-gas elements and complex systems.

$$U(r) = 4\varepsilon \left[ \left( \frac{\sigma}{r} \right)^{12} - \left( \frac{\sigma}{r} \right)^6 \right]$$

(2.5)
Multi-body potentials are very different from pair potentials. The potentials must include the effects of three or more particles interacting with each other. One typical example is embedded-atom method (EAM) potential (2.5) [7], which is based on calculation from a sum of the contributions from surrounding atoms.

\begin{equation}
E_i = F_{2\alpha}\left(\sum_{j\neq i} \rho_{\alpha\beta}(r_{ij})\right) + \frac{1}{2} \sum_{j\neq i} \phi_{\alpha\beta}(r_{ij})
\end{equation}

\text{(2.6)}

2.5 LAMMPS

There are many commercial softwares available for MD simulation (APPENDIX A). LAMMPS is one widely used in many areas. LAMMPS (Large-scale Atomic/Molecular Massively Parallel Simulator) is created and maintained by Sandia National Laboratories [8], as a free open-source code and written in C++. The details of information can be given from LAMMPS official website.

In order to make MD simulation run on LAMMPS, input file, potential file, and executable file are needed. However, to utilize LAMMPS for damage calculations, modification and extra cares are needed. Although LAMMPS provides many default potentials which predict bulk properties very well, they are not suitable for short range atomic interactions like those encountered in ion solid interactions. The standard input file of LAMMPS was provided in APPENDIX B. Besides, LAMMPS do not have functions to differentiate defects. Self-made software is needed to extract defect information. Furthermore, LAMMPS does not provide visualization capability, though this can be readily solved by using other software such as VMD and PyMOL. We have
provided the software for defect calculation as an APPENDIX C at the end. In APPENDIX C, C++ code was used to determine vacancies and interstitials by the distance.
CHAPTER III

MOLECULAR DYNAMICS SIMULATION OF DEFECT
CREATION DUE TO INTERACTIONS OF DAMAGE CASCADE IN
SELF ION IRRADIATED SI

3.1 Introduction of Gibbon’s Overlap Model

Understanding radiation damage creation in solids is important for a wide range of applications in semiconductor industry and nuclear industry. In particular case, the radiation damage is created under the high flux radiation. It is quite different from the case of low flux radiation. The ion bombardment happens independently, that means damage cascade created by one ion can’t reach to another. While when the flux is high enough, it increases the chance of damage overlap. Interactions among damage cascades created by different ions play an important role in defect formation [9]. Such interactions are particularly important in high flux ion irradiation and, as one example under extreme conditions, in cluster ion irradiation in which multiple atoms in the same cluster bombard a solid simultaneously [10].

In an analytical approach to account for the damage cascade interactions, Gibbon first introduced an overlap mode [11], based on the following assumptions: (1) each individual damage cascade is described as a partially damaged zone; and (2) the overlapping of two (or more) partially damaged zones forms a permanent damage zone. This model suggests that for two simultaneously arrived ions, the closer the proximity,
the higher the permanent damage. Later, Dennis and Hale proposed a modified model in which a single damage cascade consists of a permanently damaged core and surrounding partial damage region [12]. Following this model, for two damage cascades being close to each other, the final damage would result from the competition between the overlapping of the partial damage regions (which increases defect formation efficiency) and the overlapping of the permanent damage region (which reduces defect formation efficiency). With decreasing separation distance, permanent damage may first increase then decrease, due to the transition between two overlapping mechanisms. The above pictures, however, are not validated by atomic scale modeling. Also, it remains unclear about the nature of so called damage overlapping.

3.2 Method Used for MD Simulation of Radiation Damage Overlap

In the present study, the classical molecular dynamics code LAMMPS [13] was used to exam interactions of two damage cascades spaced in close proximity. A $<100>$ Si was bombarded simultaneously by two Si ions of 2 keV, with their initial separation distance ranging from 0.24 $nm$ (bond length for a Si dimmer) to 7.5 $nm$. The Si-Si interatomic potential was described by a Tersoff potential [14], with a smooth transition to Ziegler-Biersack-Littma at close atomic distances [15]. The cell contains 0.5 million atoms with periodical boundaries. The damage development was simulated up to 21.5 $ps$ upon ion hitting. Both Si ions hit the $<100>$ Si substrate at an incident angel of 9 ° to avoid channeling phenomenon.
3.3 Results and Discussion

Fig. 3 plots the displacements per atom as a function of separation distances. The data were collected at 1.5 ps and 21.5 ps, respectively. The most noticeable feature of both curves is the creation of peak damage at the separation distance of ~0.6 nm. At very large separation distance, the damage is low and stays at the roughly the same level. With distances reduced to be less than 1.0 nm, the damage drastically increases and reaches a peak at a separation distance of 0.6 nm. Beyond that, the damage quickly drops with reducing separation distance. For a single ion irradiation, the displacement number is 120, approximately a factor of 2 larger than what obtained from binary collision code SRIM [15]. Findings from Fig. 3 support the major features predicted by the empirical overlapping model, although the mode is based on a crude assumption on its cylindrical damage tomography [12].
Fig 3. MD simulation obtained displacement numbers at time $t = 21.5\text{ps}$ and $t = 1.5\text{ps}$

MD simulations agree with the model that at large separation distance, damage creation is independent of separation distance due to the lack of cascade interactions. If the separation distance satisfying $r_a < r < 2r_{pd}$, where $r_{pd}$ is the radius of partially damaged zone and $r_a$ the radius of permanent damage zone, damage is enhanced due to overlapping. If $r < 2r_a$, damage creation is determined by the competition between the overlapping of the partial damage and the overlapping of the permanent damage. As shown in Fig. 3, displacement peaks at $r = 0.6$ nm, which could be regarded as barely
touching of two permanent damage region with \( r_a = 0.3 \text{ nm} \). At zero separation distance with a complete overlapping, the normalized displacement per atom is \( \pi r_{pd}^2 / 2 \). Since, according to MD simulation, the displacement number at small separation distance drops to a value comparable to that of single ion irradiation, we have \( \pi r_{pd}^2 / 2 = \pi r_a^2 \). This suggest that \( r_{pd} = 0.42 \text{ nm} \), which agrees with MD simulation result that at \( \sim 1 \text{ nm} \) (\( \approx 2r_{pd} \)), displacement start to rise.

It is unclear from Fig. 3 though, at which defect development stage, overlapping leads to enhanced defect creation. For clarification, Fig. 4 (a) and 4 (b) show the displacement number changes as a function of time for \( r \leq 0.6 \text{nm} \) and \( r > 0.6 \text{nm} \), respectively. At the beginning of the collision stages (\( t < 0.2 \text{ ps} \)), displacements increase with roughly the same creation rate and defect buildups are insensitive to separation distances. At the time of a fraction of ps, displacements reach maximum, but their peak values and the times to reach these peaks, are different under different separation distances. Finally, at longer times during quenching and annealing stages, displacements drop and became saturated at different numbers.
As the first attempt to understand the separation distance dependent defect creation, we calculated defect annealing efficiency by using the final defect number (corresponding to the longest computation time \( t=21.5 \) ps) and the peak damage. As shown in Fig. 5, the ratios have small fluctuations and range from 0.5 to 0.6. On the other hand, as shown in Fig. 3 for \( t=21.5 \) ps, there are 184 displacements created for \( r=\)
7.5 nm and 124 displacements for $r=0.6$ nm. This corresponds to $\sim 50\%$ difference in defect creation, which is much larger than the small fluctuations observed in Fig. 5. As a result, we believed that the large differences in final defect numbers are primarily caused by the difference in peak damage.

![Graph showing times reaching maximum displacement numbers for two Si ions bombarding at different separation distances.](image)

**Fig 5.** The times reaching maximum displacement numbers for two Si ions bombarding at different separation distance.

Careful investigations on Fig. 3 suggest that the higher the maximum displacements, the longer the time required reaching the maximum. Fig. 6 plots the corresponding time for peak damage creation as a function of ion separation distance. Although the data
exposes fluctuations, the trend agrees in principle with that observed in Fig.4 The damage is peaked at 0.6 nm and drop at either longer separation distance or shorter distances. This observation leads to one possible explanation (yet to be verified): if overlapping changes the kinetic energy of the displacement and shifts the energy distribution upward to higher numbers, this could lead to more displacement creating, and correspondingly, requires longer time to reach maximum damage creation.

To verify the above hypothesis, Fig.7 compares the kinetic energy distributions of single ion and of dimmer at r=0.6 nm. Both distributions correspond to t=0.2 ps, which is 0.08 ps ahead of the time for the dimmer to reach maximum damage. Surprisingly, although the dimmer has enhanced defect creating at later time, there is no evidence that its kinetic energy distribution was shifted upward to a higher value. For both energy distributions, except for a few displacements having a kinetic energy of 10-13 eV, majority of the displacements has values less than 10 eV. For the dimmer, although displacements keep increasing, the kinetic energy distribution at t=0.2 ps shows that there are no atoms energetic enough to cause further displacements since all of them have kinetic energies less than the displacement threshold in Si, which is about 15 eV [16]. Thus, the observed enhanced damage under overlapping could not be explained by the standard binary collision model, since such a soft energy distribution does not expect to create defects.
Fig 6. Defect annealing efficiencies calculated by using the maximum displacements and
the final displacements at time $t = 21.5 \, \text{ps}$, for different ion separation distances.

Discussions so far suggest that the key to understand the overlapping effects is not in
the collision stage but in the thermal pike stage in which energy redistribution at low
energy region is dominant. According to the modeling works done by Santos et al.[17],
defect creations at energy below the displacement threshold are possible if the deposited
energy is high enough to induce melting. Due to quick heat dissipation after the melting,
amorphous packets are expected to form in the originally molten region [17]. Whether
an energy deposition can induce melting is determined by the competition between the
energy deposition density and the energy dissipation rate [17]. Santo et al. calculated the critical time period to melt a Si sample having different initial energy densities and found that the higher the kinetic energies, the quicker the time to covert the energy to the potential energy required for melting. The value of 1 eV/atom was found to be the threshold value for melting [17]. This number is consistent with the fact that for liquid Si at the melting temperature, the kinetic energy is about 0.3 eV/atom and the potential energy of 0.7 eV/atom [18]. For these zones having energy densities close to 1 eV/atom, the required incubation period for melting is relatively long [17]. For example, it requires 27 ps to melt a region having kinetic energy of 1 eV/atom [17]. A longer incubation period means more difficulties to induce melting due to energy dissipation. On the other hand, the region of low energy deposition density may not lead to defect formation directly, but the overlapping of such regions could increase energy deposition density and reduce the incubation period. So melting could be promoted and subsequent defect creation be enhanced. We believe such overlapping enhanced melting is the main mechanism of damage enhancement.
Fig 7. Kinetic energy distributions of displacements created at time $t = 0.2\, \text{ps}$ after bombardments by two Si ions at a separation distance of 0.6 nm. The distribution for single ion irradiation is also plotted for comparisons.

For damage cascade formation in reality, it is difficult for light ion irradiation to cause local melting since the damage tomography is featured by separated point defect formation. Even small damage zone is formed, quick energy dissipation will inhibit melting. For heavy ion irradiation, it often creates large damage cascades with in-core region well exceeding the energy deposition density of 1eV/atom. Due to very short time required to reach liquid phase formation, i.e. 35 fs for 4 eV/atom, it is reasonable to treat
this in-core region as a permanent damage region and surrounding out-core region as partial damage region. For a dimmer spaced at a very short separation distance, damage will be enhanced due to overlapping of out-core regions and, reduced due to overlapping of the in-core regions. As a result, the final defect number is determined by this competition process and depends on the ratio between two regions.

In addition to the above mechanism, enhanced melting is expected when two damage cascades interact and cause temperature enhancement in localized regions. Previous MD simulations have shown that with increasing ambient temperature, the size of molten regions in Cu increase [19]. With two damage cascade in close proximity, energy dissipation from each other will reduce temperature gradients and thus increase incubation period for melting. This may promote melting for the the region have density deposition density close to 1eV/atom.

In MD simulation, electron excitation is normally neglected. In classical theory, the electronic stopping will not lead to atomic displacements, particularly for the ion solid interaction at low energy region, as the present study. It needs to point, however, a similar thermal spike exist in the electron subsystem. Electron excitation and ionization occur in a very short time scale (of the order of $10^{-15}$ s), which is much faster than the time scale of damage cascade (of the order of $10^{-12}$ s). Thermalization of such excited electrons also occurs at a very short time scale (of the order of $10^{-15}$ s). As a result, the thermal spikes in two different subsystems (electron vs. atoms) could be separated [20]. Due to much short time scale for electron heating and thermalization, contribution of heating from electron-phonon interactions should have small effects on the melting
process. Furthermore, although two ions hit the substrate simultaneously, the difference in ion trajectories will cause some time difference in electron thermal spike formation, which makes it difficult to have spike overlapping for the electron system.

The study is critical to understand radiation damage caused by cluster ions for which multiple atoms are bonded together as a heavy project bombarding the solids [21-26]. Upon penetration, a cluster will dissociate into individual atoms after a few monolayers. But cascades causing by individual atoms from the same cluster keep close proximity, thus leading to significant overlaps. Numerous experimental studies show that cluster ion bombardments have nonlinearly enhanced irradiation damage and sputtering [21-26]. Shao et al. have applied the concept of overlapping and develop an analytical model for describing cluster ion damage [26]. The model, however, was based on the assumption that each individual damage cascade consist of partial damage only, an extension from early model from Gibbons. This present study suggests that it might necessary to introduce an amorphous core region for each damage cascade to account for the observation that at very close proximity, the defect creation efficiency drops.

In summary, using MD simulations we have shown that for two 2 keV Si ions simultaneously bombarding a Si substrate, the numbers of displacement created are sensitive to the separation distance between two atoms. Using single ion irradiation as reference, the damage per ion is enhanced and peaked at $r = 0.6\, \text{nm}$. For $r>0.6$ nm, the defect numbers decrease with increasing separation distance and approach to the value corresponding to the singe ion irradiation. For $r<0.6$ nm, the defect numbers also drops at very short separation distance. Such an observation verified the key assumption made
in the previous empirical overlapping model—the existence of permanent damage and partial damage regions. Time evolution of defect numbers shows that enhanced displacement creation does not occur in the collision stage, but in the thermal spike stage in which all displacements have energies below the displacement threshold. This suggests the damage enhancement comes from increased melting of the damage cascade regions.
CHAPTER IV

USING CLUSTER ION BOMBARDMENT TO DETERMINE AMORPHIZATION MODE

4.1 Introduction of Irradiated Amorphization

In order to extend the concept of radiation damage overlap to applications, we used silver clusters with different size bombard Strained SiGe. Strained SiGe technology has been utilized as a substrate engineering to achieve enhanced carrier mobility in advanced microelectronics [27-28]. Understanding radiation response of strained Si is important for device doping using ion impanation technique, and for evaluation of device reliability in harsh environments involving particle irradiation, such as out space. For ion bombardment of solid crystalline materials, Gibbons introduced the overlap model to describe damage accumulation as mentioned in Chapter IV [11]. This model assumes that each ion incident on a target will create a partially damaged region, and overlap of these regions will cause permanent damage [11]. It is generally believed that bulk Si follows such an overlap model [11]. But amorphization mechanism in strained Si is not known. Previous studies have shown that SiGe layers have poor radiation tolerance when compared with strain-free Si [11, 29]. In a heterogeneous Si/SiGe superlattice, the SiGe layer is preferentially amorphized under ion bombardments [11, 29]. One hypotheise, yet to be determined, is that strain may change the amorphization mechanism into a direct amorphization model, in which permanent damage forms directly upon individual ion hits, without damage overlap[30].
One primary approach to study amorphization mechanism of solids is to obtain damage buildups as a function of ion fluencies. The method, however, leads to similar fluence dependence for both direct amorphization and overlap models. In the present study, we propose to use cluster ion irradiation as a tool to study amorphization mechanism in a SiGe layer. The experiment observations were further compared with analytical mode and molecular dynamics simulations to gain insights into the mechanism.

Strained layer samples were grown by molecular beam epitaxy at 650 °C. The sample consisted of 50 nm Si$_{0.8}$Ge$_{0.2}$ on the top of a 200 nm Si buffer layer, which is grown on a <100> Si substrate. Samples were irradiated with Ag$_n$ cluster ions at room temperature with cluster size (the number of atoms in a cluster) taking $n=1,2,3,$ and 4, respectively. For all cluster sizes, energy per Ag atom is always 12 keV and the equivalent Ag atomic fluence is always $2.5 \times 10^{13}$ cm$^{-2}$. According to the Stopping and Range of Ions in Matter code[31], the projected range of Ag atoms is 12 nm. Samples were characterized by Rutherford backscattering spectrometry with a 2 MeV He analysis beam. Backscattering yields were detected by a semiconductor detector at 170°, with an energy resolution of 17 keV.

4.2 Method of MD Simulation for Irradiated Si

MD simulation was performed by using LAMMPS (Large-scale Atomic Molecular Massively Parallel Simulator) code [13]. For both Si-Si and Si-Ge pairs, Tersoff potentials [14] were smoothly connected to ZBL(Ziegler-Biersack-Littmark) potentials [15] at short atomic distances. For both Ag-Si and Ag-Fe pairs, ZBL potential are used
only due to the nature of ion-solid interactions. The target has a cell size of 35 nm × 35 nm × 35 nm which contains about 2,200,000 atoms with periodical boundary conditions. 20% Si atoms were replaced by Ge atoms randomly to simulate a Si$_{0.8}$Ge$_{0.2}$ film. Ag atoms bombard with a tilt angle of 9° from the target normal to avoid channeling effects. Damage developments were simulated at a time step of 0.25 fs.

In Gibbons’ model, partially damaged regions are created by individual ions which are randomly distributed. Thus, significant overlapping occurs only under high fluence irradiation. For cluster ion irradiation, atoms in one cluster arrive at the sample surface simultaneuously, and overlapping occurs within the cluster, regardless of cluster fluencies. The level of overlapping is determined by cluster size and distribution of an individual damage volume within a cluster. Shao et al. has derived the following analytical equation [24]

$$V_d \propto 1 - \sum_{k=0}^{m-1} \frac{(n\delta)^k}{k!} \exp(-\delta n)$$  \hspace{1cm} (4.1)

where $V_d$ is the volume of permanent damage in a cluster, $m$ is the number of overlapping required to cause permanent damage, $n$ is the cluster size and $\delta$ is volume correction factor, which is defined as the ratio of individual damage volume created by one atom ($V_s$) to the average damage volume created by one cluster ($V_c$). $V_c$ is virtually created by bombardments of atoms one by one from the same spot. Thus $V_c$ equals averaged $V_s$. Based on this picture, early data from Sigmund et al. on ratio of $V_s$
to the averaged $V_s$ can be used [32]. Through curve fitting of data in Ref. 32, we obtained the following expression

$$\delta = \{0.52 + 0.46\exp[-(M_2 / M_1)/1.02]\}^3$$  \hspace{1cm} (4.2)

Where $M_1$ and $M_2$ are mass of the incident and target atom, respectively.

4.3 Results and Discussion

Fig. 8 plots the damage creation per Ag atom ($V_d / n$) as a function of Ag cluster size $n$. The curve was predicted by using equation (4.1) with $\delta = 0.6$, which is obtained from equation (4.2) by using a mean atomic mass $M_2 = 37$ for Si$_{0.8}$Ge$_{0.2}$. For the direct amorphization model ($m=1$), damage decreases with increase sizes. This is understandable since structure collapses directly upon monomer bombardment, and any overlapping within the cluster will lead to repeated damage, which in turn reduces the power of damage creation per atom. For single overlap model ($m=2$), damage quickly increases to a saturation and slightly decreases with larger cluster size. Saturation is the result of balance between permanent damage creation due to overlapping of partial damage and repeated damage creation due to overlapping of created permanent damage. For double overlap model ($m=3$), formation of permanent damage and its subsequent overlapping are difficult for small clusters, it requires a large cluster size to reach damage saturation.
Fig 8. Permanently damaged volume created per incident atom in cluster ions with size 1 to 5 atoms, predicated from Eq. (4.1) by assuming the direct amorphization (m=1), single overlap (m=2), or double overlap (m=3) models.

Fig.9 shows channeling RBS spectra obtained from samples irradiated with Ag clusters of sizes from $n=1$ to $n=4$. For both Si and Ge signals, the backscattering yields are increasing with increasing Ag cluster sizes. The inset shows the enlarged spectra for Si damage and the straight line was used to read yields of irradiated samples ($Y$), virgin sample under channeling ($Y_{ch}$) and virgin sample under random mode ($Y_{ran}$). The fraction
of displacements at the damage peak was calculated by \( f = 1 - \frac{(Y_{\text{run}} - Y)}{(Y_{\text{run}} - Y_{r})} \).

The way to read random yield considers the resolution limit for such shallowly located damage peaks.

Fig. 9. Channeling RBS spectra of 2 MeV He ions along <100> axis in virgin and Ag\(_n\)-irradiated Si\(_{0.8}\)Ge\(_{0.2}\) layers. The random spectrum is plot for comparison.

Fig. 9 plots the extracted displacement fraction for Si and Ge. Damage is nonlinearly enhanced as a function of cluster size. The observations, in comparison with Fig. 10, lead to conclusion that the Si\(_{0.8}\)Ge\(_{0.2}\) layer does not follow a direct amorphization mode.
Further comparison to extract the value $m$ is questionable here since the analytical mode is too simplified without considering atomic scale defect interactions. The displacement ratios are ranged from about 0.2 for monomers and 0.4 for Ag$_4$ clusters. This suggests that the Ag fluence were appropriately selected: the fluence is high enough to create damage in the sensitive level for RBS (>0.02) and low enough to avoid significant overlapping between clusters. Furthermore, there is no noticeable difference between displacement creation for Si and Ge in the same Si$_{0.8}$Ge$_{0.2}$. It is obvious in Fig.10 that the enhancement of radiation damage is a function of the size of Ag cluster. That means each atom in Ag cluster creates larger damage than the damage create by single atom. This is very important if we intent to build amorphization in materials and also important for us to understand the mechanism of the interactions between energetic clusters and materials. In this case, that result is significant helpful for us to understand such amorphization phenomenon.
Fig 10. Displacements of Si and Ge atoms, extracted from Fig. 9, for Agₙ cluster ion irradiated Si₀.₈Ge₀.₂ layer.

Fig.11 shows the time dependence of displacement creation by different Agₙ clusters obtained by using MD simulations. For each curve, displacement numbers were normalized by cluster sizes. With increasing cluster sizes, both damage peak and the residual damage after thermal spike quenching increase. The largest cluster Ag₄ creates about 1000 displacements per atom at t=1ps, while Ag monomers creates only about 300 displacements per atom. The insets show the corresponding 3-D damage cascade formation at t=1ps. For monomer irradiation, damage is peaked at the projected range,
while for Ag₄ cluster, damage is peaked at the near surface region, which can be attributed to a high degree of overlapping for individual damage cascades near the surface.

Fig 11. MD simulations of displacement creation in Si₀.₈Ge₀.₂ layer upon Agₙ ion irradiation. The insets show the displacements caused by a Ag₄ cluster and by a Ag monomer at t=1ps.

Fig. 12 plots the displacement per Ag atom for different Agₙ clusters at t=1ps. The error bars represent the range of displacements created by randomly changing azimuthal angles of incident ions. Nonlinearly enhanced damage by cluster bombardment is obvious, which agree with RBS channeling data. No attempt is made in the present study
to directly compare RBS data with MD simulation since the time scale of the modeling is too short. For selected cases, MD simulation up to 20 ps has been performed which suggest the residual damage does not change too much (<20%) when compared with that at 1 ps.

Fig 12. Displacements (Si+Ge) in Ag$_n$-irradiated Si$_{0.8}$Ge$_{0.2}$ layers at $t=1$ps, obtained from MD simulations.

In a crystalline solid, introducing point defects will increase system energy. If this energy is higher than a threshold energy, structure either collapses or form large defect
clusters to reduce the energy [8]. This picture actually can explain both the heterogeneous and homogenous amorphization/permanent-damage-formation models. The primary difference between two modes is that for heterogeneous model energy increases are contributed by overlapping of damage volumes, which often occurs in heavy ion irradiation, while for homogenous model, the energy increase is caused by accumulation of point defects which often occurs in light ion irradiation. The presence of Ge atoms, together with strain and localized stress, inevitably increase the system energy. Although it is expected the required energy to achieve amorphization transition or permanent damage is reduced in strained Si, the present study suggests that the material still needs overlapping for this process.

Strain or Ge chemical effects on diffusivities of point defect and formation energy of defect clusters [33]. A small change in migration energy of mobile defects can greatly change interstitial-vacancy recombination process. Strain can also affect kinetics of defect formation. In previous study by Vos et al. [29], it was suggested that creation of displacements does not differ greatly between strained Si and Si, but the subsequent defect rearrangement of the defects plays a role in determining radiation response of the material. This is consistent with the observation from Crosby et al. those dislocation loops densities significantly increase in strained Si [34]. These observations suggest the necessity to systematically study the kinetics of defect reactions, which is beyond the scope of the present study.

In summary, based on the very different damage buildup behaviors between monomer ion irradiation and cluster ion irradiation, we proposed to use cluster ion
bombardments as a tool to understand amorphization mechanism for crystalline solids. By applying this technique to strained Si$_{0.8}$Ge$_{0.2}$ layer by using Ag$_n$ cluster ion irradiation, we have shown that the strained layer follows overlap model for amorphization/permanent damage formation. The observed nonlinear enhancement in damage formation agrees with MD simulations.
CHAPTER V

MOLECULAR DYNAMICS SIMULATION OF ION FOCUSING
AND CROWDION FORMATION IN SELF-ION IRRADIATED Fe

5.1 Introduction of Radiation Damage in Fe

In Chapters IV and V, we have talked about radiation damage in Si and SiGe, but radiation damage in metal is quite different. Studies on radiation damage in metals has been driven greatly by the needs for materials applications in harsh environments, i.e. fission and fusion reactors [35]. Progress towards fundamental understanding of defect developments has been aided by emerging atomic scale characterization and quantum mechanics many-body simulations. Among them, molecular dynamics (MD) simulation is an important modeling tool to reveal the damage development at early stage of a few picoseconds. This time scale corresponds to damage cascade formation, a phenomenon involves damage deposition and subsequent quenching process in a period so short that materials behaviors cannot be predicted by knowledge obtained under equilibrium conditions [4].

Early MD simulation showed that damage cascade is featured by a vacancy rich core surround by an interstitial shell [36]. Damage cascade forms when the mean flying distance of projectile becomes comparable to the mean atomic distance of a target solid, thus they are created when projectiles or recoiled target atoms have a typical energy of a few keVs [4]. Later MD simulations show additional features of damage cascades. A chain-like atomic displacements, so called crowdion [4], is formed along certain atomic
row directions. Crowdion is initialized from the damage cascade core, and is a consequence of subsequent displacements along an atomic row. In literature, such displacements are described as ion focusing—atomic shifting over a limited distance along the direction of one atomic row. Displacements end when the last displaced atom does not have enough kinetic energy to displace the next atom.

At the end of damage cascade formation, most point defects disappear due to kinetic defect recombination. Surviving defects begin to take stable configurations after structure relaxation [4]. These defects are precursors to extended defects, which are the source of series of materials degradation phenomenon [37-40]. In this study, crowdion formation in self ion irradiated iron (Fe) is investigated by using MD simulation to obtain further atomic scale details.

### 5.2 Method of MD Simulation for Irradiated Fe

MD simulation was performed by using LAMMPS. The details about the parallel spatial-decomposition, neighbor-finding and communication algorithms can be found in Ref. 13. The Fe-Fe interatomic potential was described by embedded-atom method (EAM) [7]. EAM is based on fitting to both experimental results and first principle calculations, and predicts thermal and mechanical properties with high accuracy. The EAM potential is generally superior to the second-moment approximation of the tight-binding method for simulation of metals [41]. In MD simulations, one 2 keV Fe atom bombarded a bcc Fe at room temperature, with an incident angle of 9° to avoid channeling effect. Random thermal oscillation of atoms, which is crucial to simulate
defect reactions, has been considered by following the standard procedure in MD simulation of damage creation [42]. The inelastic energy loss is not considered since electronic stopping is negligible for such low energy ion irradiation. The Fe target has a cell size of 14 nm × 14 nm × 14 nm which contains about 250,000 atoms. Periodical boundary conditions, except for the surface, were used but the cell size was large enough to contain a single damage cascade completely without damage overlapping. Damage developments up to 30 ps were simulated at a time step of 0.25 fs. An atom became an interstitial when it was located away from the lattice site with displacements at least 0.3 of lattice parameter [43]. A vacancy was created if there was no atom within the radius of 0.3 of lattice parameter [43]. The above criteria have been used generally in MD simulation of metals, with good sensitivity to identify dumbbell defects.

5.3 Results and Discussion

Fig.13 show damage cascade evolution at 0.1 ps, 0.3 ps, 1 ps, and 30 ps after ion bombardment. For best imaging, the cell size is much smaller than the super cell used in MD simulation. The red circles refer to vacancies and the green circles refer to interstitials. From 0.1 ps to 0.3 ps, damage cascade volume is increasing. Also at 0.3 ps, chain-like crowdion defects form with a length ranging from 2 nm to 5 nm. The crowdion defect formation is realized by a series of substituting collisions, with a typical knock-on energy close to 30 eV (Fe displacement energy). At 1 ps, significant defect recombination leads to shrinkage of the damage cascade volume. Defect recombination also restores displacements along crowdions, but leave dumbbell defects at the end of
crowdions. One dumbbell defect is featured by two interstitials sitting at each side of an empty lattice site. MD simulations show that the two interstitials are oriented along original crowdion direction. At 30 ps, most defects disappear. It is worthy to note that at this time scale dumbbell defects resulting from crowdion formation represent a considerable fraction of surviving defects.

Fig 13. Damage cascade evolution from MD simulation of a bcc <100> Fe crystal irradiated by one 1 keV Fe ion at 0.1 ps, 0.3 ps 1 ps, and 30 ps.
Fig 14. plots interstitial and vacancy numbers as a function of times. Displacements first increases, then decrease at a time longer than 0.3 ps. Interstitial and vacancy numbers are roughly the same at the beginning but vacancies begin to be slightly richer at about 0.3 ps, which corresponds to the time reaching a maximum cascade volume. Our analysis further suggests that the defect imbalance is caused by sputtering of atoms from the surface, which occurs when the damage cascade begins to touch the surface significantly.

Fig 14. Numbers of interstitials and vacancies as a function of times after 2 keV Fe ion bombardment of a bcc <100> Fe crystal.
One important feature observed in Fig. 14 is that beyond 0.3 ps, defect numbers show a second peak at about 0.45 ps. The time dependent damage buildups can be described by a small Gaussian peak superimposed on a big one. The second peak is attributed to delayed defect creation due to crowdion formation. While the damage cascade core begins to have defect recombination, crowdions are being formed. The time difference between 0.3 ps and 0.45 ps represents an effective lifetime of crowdion defects. The defects survived from crowdion relaxation play a role in determining the tail region of the curve. From 0 to 0.3 ps, the displacement buildups have a smooth curve which means the total number of defects is large enough that two peaks observed cannot be explained by statistic fluctuations. This has been further confirmed by repeating ion bombardment with different bombardment conditions, i.e. by changing incident angles. Fig. 15 shows a more clearly picture that two Gaussian curves are used to fit it. It is obvious that the process consists of two parts, one comes from the crowdion creation, the other one comes from the normal thermal spike. That prove the importance the crowdion in the damage cascade formation.
Fig 15. Number of interstitials in a bcc <100> Fe crystal caused by a 2 keV Fe ion.

Fig.16 shows the relaxation of a typical crowdion defect as a function of times. At beginning, the crowdion is aligned along <111> direction. With increasing times, crowdion shrinks and, at times beyond 0.6 ps, the survived dumbell defects begin to rotate towards <110> direction. Fig.17 plots the orientation of defects, the angle between one dumbell defect and (100) plane, as a function of time. At the time of 0.83 ps, the angle becomes zero and dumbbell defect is perfectly align along the <110> direction.
Vacancy in Fe has an inward relaxation and interstitials has an outward relaxation [1]. The strain field around one vacancy is compensated by inserting an interstitial. Thus forming a dumbbell defect cost less energy than forming three isolated point defects. <110> oriented dumbbell defects have been identified by previous studies as the preferred defect configuration in most bcc metals [1]. Consider that <110> direction has the largest atomic distance, the energy cost to insert one interstitial along <110> is the least. The dumbbell defects are mobile and subsequent defect clustering leads to larger defects.

Fig 16. Images of typical crowdion and dumbbell defect evolution from MD simulation.
Fig 17. Angles between the (100) plane and the dumbbell defect orientation as a function of times upon 2 keV Fe ion bombardment. The zero degree corresponds to the perfect alignment along <110> direction.

The present study shows that crowdion defect formation is an important mechanism for displacement transport in the damage cascade formation. Dumbell defects are scattered in a region larger than the damage cascades and crowdion induced dumbbell defects contribute significantly to the defect developments.

MD simulation has shown that crowdion defects formed in bcc Fe are propagating along <111> directions. Crowdion defect starts to form when damage cascade reaches the maximum volume and contributes a second peak in defect buildups with increasing
times. Upon defect recombination, crowdion defects shrink and form \(<111>\) oriented dumbbell defects at the crowdion end. In subsequent structural relaxation, \(<111>\) dumbbell defects rotate and finally align themselves with \(<110>\) directions. The surviving dumbbell defects represent a significant contribution to the final defect distribution after thermal spike formation.
CHAPTER VI
CONCLUSION

Molecular dynamic simulation has been used to simulate damage cascade formation in ion bombarded solids. Based on MD simulations result, we have shed light into atomic scale of damage cascade formation in selected ion-target systems.

In the Chapter V the formation and structural relaxation of crowdion in self ion irradiated Fe were studied. MD simulation has shown that crowdion defects formed in bcc Fe are propagating along <111> directions. Crowdion defect starts to form when damage cascade reaches the maximum volume and contributes a second peak in defect buildups with increasing times. Upon defect recombination, crowdion defects shrink and form <111> oriented dumbbell defects at the crowdion end. In subsequent structural relaxation, <111> dumbbell defects rotate and finally align themselves with <110> directions. The surviving dumbbell defects represent a significant contribution to the final defect distribution after thermal spike formation. It is concluded that crowdion forms along the direction with highest linear atomic density and crowdion subsequently rotates toward the direction has the lowest atomic density. In addition, crowdion play an important role for determining defect tomography.

In Chapter III MD simulations show that for two 2 keV Si ions simultaneously bombarding a Si substrate, the numbers of displacement created are sensitive to the separation distance between two atoms. Using single ion irradiation as reference, the damage per ion is enhanced and peaked at $r = 0.6 \text{nm}$. For $r > 0.6$ nm, the defect numbers
decrease with increasing separation distance and approach to the value corresponding to
the single ion irradiation. For r<0.6 nm, the defect numbers also drops at very short
separation distance. Such an observation verified the key assumption made in the
previous empirical overlapping model—the existence of permanent damage and partial
damage regions. Time evolution of defect numbers shows that enhanced displacement
creation does not occur in the collision stage, but in the thermal spike stage in which all
displacements have energies below the displacement threshold. This suggests the
damage enhancement comes from increased melting of the damage cascade regions.

Based on the very different damage buildup behaviors between monomer ion irradiation
and cluster ion irradiation in Chapter IV, we proposed to use cluster ion bombardments
as a tool to understand amorphization mechanism for crystalline solids. By applying this
technique to strained Si$_{0.8}$Ge$_{0.2}$ layer by using Ag$_n$ cluster ion irradiation, we have show
that the strained layer follows overlap model for amorphization/permanent damage
formation. The observed nonlinear enhancement in damage formation agrees with MD
simulations. The defect formation/amorphization mechanisms of strained SiGe
alloy. Although the strained layer has less radiation tolerance, the defect formation still
follows single overlap model, as that of nonstrianed Si.
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APPENDIX A

list of MD simulation software

- AutoDock suite of automated docking tools,
- Autodock Vina improved local search algorithm, suite of automated docking tools,
- Abalone (classical, implicit water)
- ABINIT (DFT)
- ACEMD (running on NVIDIA GPUs: heavily optimized with CUDA)
- ADUN (classical, P2P database for simulations)
- AMBER (classical)
- Ascalaph (classical, GPU accelerated)
- CASTEP (DFT)
- CPMD (DFT)
- CP2K (DFT)
- CHARMM (classical, the pioneer in MD simulation, extensive analysis tools)
- COSMOS (classical and hybrid QM/MM, quantum-mechanical atomic charges with BPT)
- Desmond (classical, parallelization with up to thousands of CPU’s)
- Culgi (classical, OPLS-AA, Dreiding, Nerd, and TraPPE-UA force fields)
- DL_POLY (classical)
- ESPResSo (classical, coarse-grained, parallel, extensible)
- Fireball (tight-binding DFT)
- GPIUTMD (classical, accelerated by GPUs, optimized with CUDA)
- GROMACS (classical)
- GROMOS (classical)
- GULP (classical)
- Hippo (classical)
- HOOMD-Blue (classical, accelerated by NVIDIA GPUs, heavily optimized with CUDA)
- Kalypso MD simulation of atomic collisions in solids
- LAMMPS (classical, large-scale with spatial-decomposition of simulation domain for parallelism)
- LPMD Las Palermas Molecular Dynamics: flexible an modular MD.
- MacroModel (classical)
- MACSIMUS (classical, polarizability, thread-based parallelization)
- MDynaMix (classical, parallel)
- MOLDY (classical, parallel) latest release
- Materials Studio (Forcite MD using COMPASS, Dreiding, Universal, cvff and pcff forcefields in serial or parallel, QMERA (QM+MD), ONESTEP (DFT), etc.)
- MOSCITO (classical)
- NAMD (classical, parallelization with up to thousands of CPU's)
- nano-Material Simulation Toolkit
- NEWTON-X (ab initio, surface-hopping dynamics)
- ORAC (classical)
- ProtoMol (classical, extensible, includes multigrid electrostatics)
- PWscf (DFT)
- RedMD (coarse-grained simulations package on GNU licence)
- S/PHI/nX (DFT)
- SIESTA (DFT)
- Tremolo-X
- VASP (DFT)
- TINKER (classical)
- YASARA (classical)
- XMD (classical)
APPENDIX B

Standard input file for LAMMPS

# Initialization

clear

units metal

dimension 3  # Dimensions of space for simulation. 3D is default

newton on on on  # Newton's 3rd law for pairwise and bonded interactions

# Processors n m o define the proc. grid

boundary p p p  # Rules or boundary

atom_style atomic  # Rules for atom styles. Atomic is default

    # atom_modify

# Atom definition

read_data polyfe.lammps

#read_restart restartGBfe27w

lattice bcc 1
region 1 block 95 98.08908 0 98.08908 0 98.08908
region 2 block -20 95 0 98.08908 0 98.08908

group group1 region 1

group group2 region 2

group id id 83740

#group id2 id 432002

#Settings

mass 1 55.845

pair_style eam/fs

pair_coeff * * Fe_mm.eam.fs Fe

min_style sd

minimize 1.0e-12 1.0e-12 1000 1000

#velocity all create 100 56565

#velocity group1 create 300 54545 rot yes dist gaussian
velocity group2 create 300 54545 rot yes dist gaussian
velocity all zero linear
velocity all zero angular
fix 1 group2 npt 300 300 1 aniso NULL NULL 0.0 0.0 0.0 0.0 10 drag 1.0
#fix 1 group2 nvt 100 100 1.0 drag 0.2
#fix 1 all nve
fix 11 group1 setforce 0 0 0

#set atom 216001 x -5 y 57.75 z 58

#velocity id set 820.205 130.085 42.985
#velocity id set 0 0 0
fix 3 id setforce 0 0 0
#fix 4 id2 setforce 0 0 0
compute 1 all ke/atom

#min_style cg

#run_style verlet
thermo 10
timestep 0.0005
dump atom all xyz 100 grainfe.xyz

#dump atoms all custom 100 feGB1ps-15 id x y z c_1

run 1000

unfix 1

#write_restart restartGBfe-151ps
APPENDIX C

C++ code for determining vacancy and interstitial

```cpp
#include <fstream>
#include <iostream>
#include <math.h>
#include <vector>
using namespace std;

float rad = 0.86, range = 130;
float stable = 0.5;
float maxx = 127;
float maxy = 127;
float maxz = 127;
float minx = 2;
float miny = 1;
float minz = 1;
float sBox = 2;
float eBox = 127;
float coe = 2;
//int SK = 2;
//int step = 5;
void main()
{
    char filename[] = "data/sample.xyz";
    char firstFrame[] = "data/standrad.xyz";
    char searchFile[] = "data/sample";
    char savefilename[] = "data/A.SEG";
    char savefilename2[] = "data/B.txt";
    char savefilename3[] = "data/C.SEG";
    char savefilename4[] = "data/D.txt";

    char NumString[20];
    char keyword[256];
    int Num, temp, n = 0, count = 0;
    float posx, posy, posz;
    float posxx, posyy, poszz;
    float nposx, nposy, nposz;
    float xxx, yyy, zzz, vvv;
    float dis, dis1, dis2, dis3;
    float min, max;
    vector<float> px, py, pz;
    vector<float> tx, ty, tz;
    vector<float> cx, cy, cz;
    vector<float> vx, vy, vz, vv;
    vector<int> sphereStat;
    vector<int> atomStat;
```
ifstream is(filename, ios::in);
ifstream is3(searchFile, ios::in);
ifstream sds(firstFrame, ios::in);
ofstream ofs(savefilename,ios::out);
ofstream ofs2(savefilename2,ios::out);
ofstream ofs3(savefilename3,ios::out);
ofstream ofs4(savefilename4,ios::out);
ofs<< "from pymol.cgo import *"<<endl;
ofs<<"from pymol import cmd"<<endl;
ofs<<"box = ["<<endl;
ofs<<"LINEWIDTH, 1.0,"<<endl;
ofs<<"BEGIN, LINES,"<<endl;
ofs<<"COLOR, 0.8, 0.8, 0.8,"<<endl;
ofs<<"VERTEX,"<<eBox<<","<<eBox<<","<<eBox<<","<<endl;
ofs<<"VERTEX,"<<eBox<<","<<sBox<<","<<eBox<<","<<endl;
ofs<<"VERTEX,"<<eBox<<","<<sBox<<","<<eBox<<","<<endl;
ofs<<"COLOR, 0.5, 1.0, 0.5,"<<endl;
ofs<<"VERTEX,"<<sBox<<","<<sBox<<","<<sBox<<","<<endl;
ofs<<"VERSE,"<<sBox<<","<<eBox<<","<<sBox<<","<<endl;
ofs<<"COLOR, 0.8, 0.8, 0.8,"<<endl;
ofs<<"VERTEX,"<<eBox<<","<<sBox<<","<<eBox<<","<<endl;
ofs<<"VERS"<<eBox<<","<<sBox<<","<<sBox<<","<<endl;
ofs<<"VERS"<<eBox<<","<<eBox<<","<<sBox<<","<<endl;
ofs<<"VERS"<<eBox<<","<<sBox<<","<<eBox<<","<<endl;
ofs<<"VERS"<<eBox<<","<<eBox<<","<<sBox<<","<<endl;
ofs<<"VERS"<<eBox<<","<<eBox<<","<<eBox<<","<<endl;
ofs<<"VERS"<<eBox<<","<<sBox<<","<<eBox<<","<<endl;
ofs<<"VERS"<<eBox<<","<<eBox<<","<<sBox<<","<<endl;
ofs<<"VERS"<<eBox<<","<<eBox<<","<<sBox<<","<<endl;
ofs<<"VERS"<<eBox<<","<<sBox<<","<<eBox<<","<<endl;
ofs<<"VERS"<<eBox<<","<<sBox<<","<<sBox<<","<<endl;
char str2[1024];
char str3[1024];
is.getline(str, 1024);
scanf(str, "%d", &Num);
itoa(Num, NumString, 10);
is.getline(str, 1024);
sds.getline(str2, 1024);
sds.getline(str2, 1024);

for (int i = 0; i < 9; i++)
    is3.getline(str3, 1024);

for (int i = 0; i < Num; i++)
{
    is.getline(str, 1024);
    sds.getline(str2, 1024);
    is3.getline(str3, 1024);
    sscanf(str, "%d %f %f %f", &temp, &posx, &posy, &posz);
    tx.push_back(posx);
    ty.push_back(posy);
    tz.push_back(posz);
    sphereStat.push_back(0);
    atomStat.push_back(0);
}

cx.resize(Num);
cy.resize(Num);
cz.resize(Num);
px.resize(Num);
py.resize(Num);
px.resize(Num);
vx.resize(Num);
vy.resize(Num);
vz.resize(Num);
vv.resize(Num);

ofs<<"# FRAME 	"<<count<<endl;
ofs<<"atoms = ["<<endl;
ofs<<"    "]"<<endl;
ofs<<endl;
ofs<<"obj = box + atoms"<<endl;
ofs<<endl;
ofs<<"cmd.load_cgo(obj,'segment', 	"<<count<<")"<<endl;
ofs<<endl;
ofs3<<"# FRAME 	"<<count<<endl;
ofs3<<"atoms = ["<<endl;
ofs3<<"    "]"<<endl;
ofs3<<endl;
ofs3<<"obj = atoms + atoms"<<endl;
ofs3<<endl;
ofs3<<"cmd.load_cgo(obj,'segment', "<<count<<")"<<endl;
ofs3<<endl;

int test_count = 0;
while(!is.eof())
{
    for(int i=0; i<9; i++)
        is3.getline(str3, 1024);
    is.getline(str,1024);
    sds.getline(str2,1024);
    if(strcmp(str, NumString) == 0)
    {
        test_count++;
        cout<<test_count<<endl;
        is.getline(str,1024);
        sds.getline(str2,1024);
        count++;
        if(count <=0 )
            continue;
        n++;
        ofs3<<"# FRAME     "<<count<<endl;
ofs3<<"atoms = ["<<endl;
ofs3<<"# FRAME     "<<count<<endl;
ofs4<<"# FRAME     "<<count<<endl;
ofs3<<"atoms = ["<<endl;
cout<<"start processing frame "<<count<<"!"<<endl;
for(int i=0;i<Num;i++)
{
    atomStat[i] = 1;
    sphereStat[i] = 1;
}

for(int i=0;i<Num;i++)
{
    is.getline(str,1024);
    sds.getline(str2,1024);
    is3.getline(str3, 1024);
    sscanf(str, "%d %f %f %f",&temp,&nposx,&nposy,&nposz);
    sscanf(str2, "%d %f %f %f",&temp,&posxx,&posyy,&poszz);
    sscanf(str3, "%d %f %f %f %f",&temp,&xxx,&yyy,&zzz,&vvv);
    cx[i] = nposx;
    cy[i] = nposy;
    cz[i] = nposz;
    px[i] = posxx;
    py[i] = posyy;
    pz[i] = poszz;
    vx[i] = xxx;
    vy[i] = yyy;
    vz[i] = zzz;
    vv[i] = vvv;
dis = sqrt((nposx-px[i])*(nposx-px[i])+(nposy-py[i])*(nposy-py[i])+(nposz-pz[i])*(nposz-pz[i]));

if(dis>stable && dis<range)
{
    for(int j=0;j<Num;j++)
    {
        dis2=sqrt((nposx-px[j])*(nposx-px[j])+(nposy-py[j])*(nposy-py[j])+(nposz-pz[j])*(nposz-pz[j]));
        if(dis2<rad)
        {
            atomStat[i] = 0;
            sphereStat[j] = 0;
            break;
        }
    }
}
else
{
    atomStat[i] = 0;
    sphereStat[i] = 0;
}

// if(count==2)
{
    ofs<<"COLOR,0.000,1.000,0.000,"<<endl;
    int c1=0,c2=0;
    for(int i=0;i<Num;i++)
    {
        if(atomStat[i]==1)
        {
            if(cx[i]<=maxx && cy[i]<=maxy && cz[i]<=maxz &&
                cx[i]>=minx && cy[i]>=miny && cz[i]>=minz)
            {
                c1++;
            }
            ofs<<"SPHERE,"<<cx[i]<<","<<cy[i]<<","<<cz[i]<<","<<0.7<<","<<endl;
            for(int j=0; j<Num; j++)
            {
                //cout<<vv[j]<<endl;
                float dis = abs(cx[i]-vx[j])+abs(cy[i]-vy[j])+abs(cz[i]-vz[j]);
                if(dis<0.0001)
ofs4<<vv[j]<<endl;
    if(vv[j]>15)
    {
        //cout<<vv[j]<<endl;
    }

ofs3<<"COLOR,1.000,0.000,0.000,"<<endl;
ofs3<<"SPHERE,"<<cx[i]<<","<<cy[i]<<","<<cz[i]<<","<<1<<","<<endl;
    if(vv[j]<15 && vv[j]>3)
    {
        //cout<<vv[j]<<endl;
    }

ofs3<<"COLOR,2.000,1.000,0.000,"<<endl;
ofs3<<"SPHERE,"<<cx[i]<<","<<cy[i]<<","<<cz[i]<<","<<1<<","<<endl;
    if(vv[j]<3 && vv[j]>0.5)
    {
        //cout<<vv[j]<<endl;
    }

ofs3<<"COLOR,1.000,1.000,0.000,"<<endl;
ofs3<<"SPHERE,"<<cx[i]<<","<<cy[i]<<","<<cz[i]<<","<<1<<","<<endl;
    if(vv[j]<0.5 && vv[j]>0.1)
    {
        //cout<<vv[j]<<endl;
    }

ofs3<<"COLOR,0.000,1.000,0.000,"<<endl;
ofs3<<"SPHERE,"<<cx[i]<<","<<cy[i]<<","<<cz[i]<<","<<1<<","<<endl;
    if(vv[j]<0.1 && vv[j]>0.05)
    {
        //cout<<vv[j]<<endl;
    }

ofs3<<"COLOR,0.000,1.000,1.000,"<<endl;
ofs3<<"SPHERE,"<<cx[i]<<","<<cy[i]<<","<<cz[i]<<","<<1<<","<<endl;
    if(vv[j]<0.05 && vv[j]>0)
    {
        //cout<<vv[j]<<endl;
    }

ofs3<<"COLOR,0.000,0.000,1.000,"<<endl;
ofs3<<"SPHERE,"<<cx[i]<<","<<cy[i]<<","<<cz[i]<<","<<1<<","<<endl;
    break;
ofs<<"COLOR,1.000,0.000,0.000,"<<endl;
for(int i=0;i<Num;i++)
{
        if(sphereStat[i]==1)
        {
                if(px[i]<=maxx && py[i]<=maxy && pz[i]<=maxz &&
                 px[i]>=minx && py[i]>=miny && pz[i]>=minz)
                        ofs<<"SPHERE,"<<px[i]<<","<<py[i]<<","<<pz[i]<<"","<<0.7<<"","<<endl;
                        c2++;
        }
}
ofs2<<count<<" "<<c1<<" "<<c2<<endl;
ofs<<"    "]"<<endl;
ofs<<endl;
ofs<<"obj = box + atoms"<<endl;
ofs<<endl;
ofs<<"cmd.load_cgo(obj,'segment', "<<count<<")"<<endl;
ofs<<endl;
ofs3<<" ]"<<endl;
ofs3<<endl;
ofs3<<"obj = box + atoms"<<endl;
ofs3<<endl;
ofs3<<"cmd.load_cgo(obj,'segment', "<<count<<")"<<endl;
ofs3<<endl;
for(int i=0;i<Num;i++)
{
        tx[i] = cx[i];
        ty[i] = cy[i];
        tz[i] = cz[i];
}
}
cout<<count<<" records"<<endl;
sds.close();
is.close();
is3.close();
ofs.close();
ofs2.close();
ofs3.close();
ofs4.close();
cout<<" done!"<<endl;
VITA

Di Chen was born in Nei Mongol, China. He started college in 2001 at Jilin University. He graduated with a bachelors degree in physics in July 2005. He started graduate study in 2005 at Peking University, and graduated with a Master of Science degree in nuclear physics in July 2008. He entered Texas A&M University in September 2008. His research areas are mainly on molecular dynamics simulation of radiation damages. He can be contacted through the Department of Nuclear Engineering, Texas A&M University, College Station, Texas 77843-3133.